

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of : June 13, 2007  
Kenichi Tajima : Group Art Unit: 2871  
Serial No. 10/711,604 : Examiner: Dung T. Nguyen  
Filed: September 28, 2004 : IBM Corporation  
Title: METHOD OF  
MANUFACTURING A LIQUID  
CRYSTAL DISPLAY  
PANEL : Dept 18G/Bldg. 300-482  
2070 Route 52,  
Hopewell Junction,  
New York 12533-6531

**INFORMATION DISCLOSURE STATEMENT**

Commissioner of Patents and Trademarks  
Washington, DC 20231

Sir:

Pursuant to 37 CFR 1.97(e), the Applicants call the attention of the Examiner to the references listed on the attached Form PTO-1449. All of the references submitted herewith were cited in a communication from a foreign patent office in a counterpart application.

If a fee is believed to be necessary, the Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. 09-0458.

Respectfully submitted,  
KENICHI TAJIMA

By:

  
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FORM PTO-1449 (Modified)  LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT  (Use several sheets if necessary)	ATTY. DOCKET NO.	SERIAL NO.
	JP920030190US1	10/711,604
	APPLICANT: <b>KENICHI TAJIMA</b>	
	FILING DATE: <b>09/28/2004</b>	GROUP: <b>2871</b>

**REFERENCE DESIGNATION**      **U.S. PATENT DOCUMENTS**

EXAMINER INITIALS	DOCUMENT NUMBER	ISSUED DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)
A1						
A2						
A3						
A4						
A5						
A6						
A7						

**FOREIGN PATENT DOCUMENTS**

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
B1	JP2003233330A	2003-08-22	JAPAN				
B2	JP2001281678A	2001-10-10	JAPAN				
B3	JP2001222017A	2001-08-17	JAPAN				

**OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)**

C1	
C2	
C3	
C4	
C5	

EXAMINER      DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.